Application Number:	10694986						
Filing Date:	29	29-Oct-2003					
Title of Invention:	Me se	Method for removing resist pattern and method for manufacturing semiconductor device					
First Named Inventor:	Masaharu Nagai						
Filer:	Jo	John F. Hayden/Andrea Turner					
Attorney Docket Number:	12	12732-171001					
Filed as Large Entity	•						
Utility Filing Fees							
Description		Fee Code	Quantity	Amount	Sub-Total in USD(\$)		
Basic Filing:			1				
Pages:							
Claims:							
Claims in excess of 20		1202	1	50	50		
Miscellaneous-Filing:							
Petition:							
Patent-Appeals-and-Interference:							
Post-Allowance-and-Post-Issuance:							

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)	
Miscellaneous:					
Request for continued examination	1801	1	790	790	
	Tota	Total in USD (\$)			